



PATENT  
Docket No. 36084200610

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In the application of:

Masao TOMIKAWA et al.

Serial No. 10/790,800

Filing Date: March 3, 2004

For: POSITIVE PHOTOSENSITIVE RESIN  
PRECURSOR COMPOSITION AND  
PROCESS FOR PRODUCING THE  
SAME

Examiner: John S. Y. Chu

Group Art Unit: 1752

**AMENDMENT UNDER 37 CFR 1.111**

**MS Amendment**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Action dated March 7, 2005, please amend this application as follows:

The specification amendments begin on page 2.

The listing of claims begins on page 3.

The Remarks begin on page 8.